

26-30 September 2017

HERCULES Laboratory

University of Évora

Workshop Day I - September 26th

Session held in room 205 - Vimioso Palace

9:15 – Welcome session: António Candeias

9:30-10:30 – Chemistry of selected organic materials used in cultural heritage artefacts: Cristina Barrocas Dias

Overview of the history and chemistry of selected natural organic materials analysed during the practical sessions of the workshop.

10:30-11:00 - Coffee Break

11:00-12:00 - Chemistry of selected synthetic polymers: Ester Ferreira

Overview of the history and chemistry of the synthetic polymers analysed during the practical session of the workshop.

12:00-13:00 – Mass spectrometry: Helena Florêncio

13:00-14:30 - Lunch in Palácio do Vimioso

14:30-15:30 – Py-GC-MS for the analysis of cultural heritage materials: Klaas Ian van den Berg and Henk van Keulen

15:30-16:30 - SPME-GC-MS for the analysis of cultural heritage materials: Christopher Maines

In addition to an overview of SPME, the lecture will concentrate on the analysis of exhibition and storage materials intended for use in close proximity to or in contact with cultural heritage materials.

16:30-17:00 – Coffee break

17:00-18:00 - Visit to HERCULES Laboratory

Workshop Day 2 - September 27th

Sessions held in HERCULES Laboratory / Mitra Campus

(Participants divided into two groups)

Hands-on session on the analysis by Py-GC-MS of natural and synthetic materials with/without derivatization by TMAH.

Hands-on session of SPME-GC-MS analysis of exhibition and storage materials used with cultural heritage artefacts.

Main instructors:

HERCULES Laboratory - Ana Manhita, Dora Teixeira, Henk van Keulen and Michael Schilling

Mitra Campus – Maria João Cabrita, Marco Gomes da Silva and Christopher Maines

Group 1: Practical session Py-GC-MS 9:00-12:30 (HERCULES Laboratory)

> Group 2: Practical session SPME-GC-MS (Mitra Campus)

Coffee break: mid morning

12:30-14:00 - Lunch in Mitra Campus

14:00-17:30 Group 2: Practical session Py-GC-MS (HERCULES Laboratory)

> Group I: Practical session SPME-GC-MS (Mitra Campus)

Coffee break: mid afternoon

Workshop Day 3 - September 30th

(This session is included in the workshop and open to some additional participants that have already preregistered)

Session held in conference room of FEA (the same of the Meeting)

9:00-11:00 - General use of AMDIS and Excel for data treatment: Michael Schilling and Henk van Keulen

11:00-11:30 - Coffee Break

11:30-13:00 - General use of AMDIS and Excel for data treatment: Michael Schilling and Henk van Keulen

13:00-14:30 – Lunch in Colégio Espírito Santo

Session held in Colégio Espírito Santo (Participants divided into two groups)

Data treatment of the Py-GC-MS and SPME-GC-MS analysis done during the hands-on session of the workshop.

14:30-16:00 - Group 1: ESCAPE for natural paint media and coatings: Henk Van Keulen

> Group 2: ESCAPE for synthetic paint media: Michael Schilling

16:00-16:30 - Coffee break

16:30-18:00 - Group 2: ESCAPE for natural paint media and coatings: Henk Van Keulen

> Group 1: ESCAPE for synthetic paint media: Michael Schilling